



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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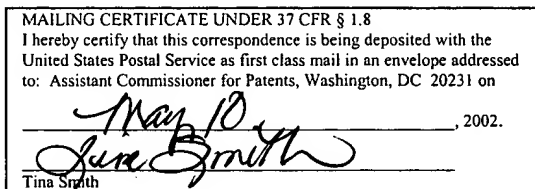
In the application of:

	Wilk <i>et al.</i>	Docket:	TI-24742
Serial No.:	09/176,422	Examiner:	N. Berezny
Filed:	10/21/98	Art Unit:	2823
For:	Low Temperature Method for Forming a Thin, Uniform Oxide		

INFORMATION DISCLOSURE STATEMENT

May 10, 2002

Assistant Commissioner For Patents
Washington, D. C. 20231



Examiner:

Applicants wish to bring to the attention of the Patent and Trademark Office the information noted on the enclosed PTO-1449.

All of these reference(s) were first cited in a communication from a foreign patent office in a counterpart foreign application not more than three months prior to filing this statement.

Copies of the European Search Report and reference(s) CA - CI are enclosed. Applicants believe that no fee is due. However, the Commissioner is authorized to charge any necessary fee to Deposit Account 20-0668 of Texas Instruments Incorporated.

Respectfully submitted,

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